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## FACSIMILE COVER SHEET

To: Commissioner for Patents	Total Pages Sent: 13
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Facsimile Number: 571-273-8300	Transmission Date: December 14, 2006

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

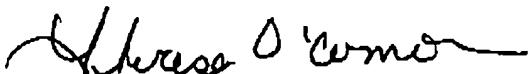
Applicant: Haupt	Docket No.: INTECH 3.0-104
	(2003 P 51718 US)
Serial No: 10/766,053	Art Unit: 2822
Date Filed: January 28, 2004	Examiner: Thanh Y. Tran
Title: Method for N+ Doping of Amorphous Silicon and Polysilicon Electrodes in Deep Trenches	

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I hereby certify that the following papers are being transmitted by facsimile to the U.S. Patent and Trademark Office at 571-273-8300 on the date shown above:

- Certification of Facsimile Transmission (1 page)
- Amendment (12 pages)

Respectfully submitted,

  
Theresa L. O'Connor  
Legal Assistant

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For: Method for N+ Doping of Amorphous Silicon and Polysilicon Electrodes  
in Deep Trenches

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

AMENDMENT

Dear Sir:

The following amendments and remarks are presented in response to the Examiner's Office Action mailed September 27, 2006. Please amend the above-referenced application as follows.

INTECH 3.0-104  
(2003 P 51718 US)

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